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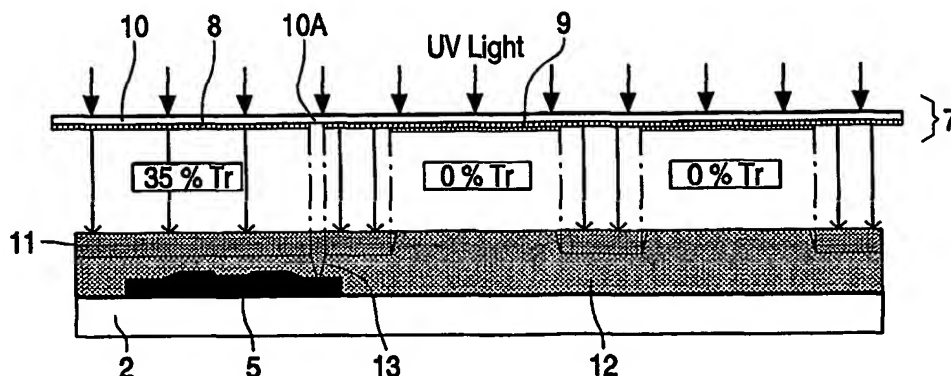
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(54) Title: MANUFACTURE OF SHAPED STRUCTURES IN LCD CELLS, AND MASKS THEREFOR



(57) Abstract: A method of forming shaped structures in liquid crystal display cells, comprises applying a photosensitive layer (6) to a transistor plate (2), and forming the shaped structures on the photosensitive layer in a photolithographic process using a grey-tone photo mask (7, 21). This mask comprises at least one region of semi-transparent material (8, 16, 18), the degree of transparency of which is dependent on the optical band gap of the material.

WO 2004/055580 A1



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